Refine Search

Search Results -

Terms	Documents
L1 and ((remov$ or etch$) near5 (oxide near4 oxynitride)).clm.	14

Database:

US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
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Search: L6

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Search History

DATE: Sunday, October 23, 2005   Printable Copy   Create Case

Set Name	Query	Hit Count	Set Name
side by side			result set
	DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L6	L1 and ((remov$ or etch$) near5 (oxide near4 oxynitride)).clm.	14	L6
L5	L4	25	L5
	DB=USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L4	L3	25	L4
	DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ		
L3	L2 and (form$ near4 oxide)	36	L3
L2	L1 and ((remov$ or etch$) near5 (oxide near4 oxynitride))	74	L2
L1	(ammonia or "NH.sub.3") same oxynitride same oxide	1671	L1

END OF SEARCH HISTORY